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Laser-induced particle size tuning and structural transformations in germanium nanoparticles prepared by stain etching and colloidal synthesis route

Ali Karatutlu,^{1,2,a)} William Little,¹ Osman Ersoy,¹ Yuanpeng Zhang,¹ Isa Seker,³ and Andrei Sapelkin¹

¹Centre for Condensed Matter and Materials Physics, School of Physics and Astronomy, Queen Mary, University of London, London E1 4NS, United Kingdom

²Electrical and Electronics Engineering, Bursa Orhangazi University, 16310 Yıldırım/Bursa, Turkey

³Bio-Nanotechnology Research and Development Centre, Fatih University, 34500 Buyukcekmece, Istanbul, Turkey

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In this study, with the aid of Raman measurements, we have observed transformations in small (~ 3 nm and ~ 10 nm) free-standing Ge nanoparticles under laser light exposure. The nanoparticles were obtained by the chemical stain etching of a monocrystalline Ge wafer and of Ge powder and by colloidal synthesis route. We found that the transformation path depends on laser power and exposure time. At relatively low values of the laser power (2 mW) over a period of 100 min, the Raman signal indicates transformation of the sample from a nanocrystalline to bulk-like state, followed by partial oxidation and finally a conversion of the entire sample into alpha-quartz type GeO₂. However, when the laser power is set at 60 mW, we observed a heat release during an explosive crystallization of the nanocrystalline material into bulk Ge without noticeable signs of oxidation. Together with the transmission electron microscopy measurements, these results suggest that the chemical stain etching method for the preparation of porous Ge may not be a top-down process as has been widely considered, but a bottom up one. Systematic studies of the laser exposure on Ge nanoparticles prepared by colloidal synthesis results in the fact that the explosive crystallisation is common for H-terminated and partially disordered Ge nanoparticles regardless of its particle size. We suggest possible bio-medical applications for the observed phenomena. © 2015 AIP Publishing LLC.

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I. INTRODUCTION

Germanium (Ge) nanomaterials were recently demonstrated to have a great potential in applications including lithium ion batteries,¹ photonics,² and bio-imaging.^{3,4} Over the last 20 years, Ge nanoparticles were shown to be synthesized using several physical and chemical methods.^{5–17} Furthermore, the crystallization of amorphous Ge (a-Ge) and a low cost of forming epitaxy were also shown using various light sources such as excimer laser,^{18,19} pulsed-laser,^{20–22} flash lamp,²³ and diode laser.²⁴ Upon the exposure of amorphous samples to the light sources, a phenomenon called “explosive crystallization” can be accompanied by an energy release and can be observed under a microscope as formation of concentric shells on the amorphous surface of the film.^{24,25} This energy release is the latent heat of crystallisation caused by a transition from the amorphous state of the sample to its crystalline state. The effect is not only limited to Ge but also can be observed in other materials,^{25,26} and the explosive crystallization effect was observed in hydrogenated amorphous samples.²⁷ However, the effect in the latter was believed to be due to the release of the hydrogen

from the sample which might form bubbles and can explode in sufficient concentrations.²⁸ At the same time, a variety of nanoparticles—mostly gold^{29–32} and graphene^{33–36}—were used in photothermal therapy (PTT) due to their high thermal conductivity. We previously showed that H-terminated Ge nanoparticles can exhibit good biocompatibility at a cellular level and can be used in bio-imaging applications.³⁷ Surface functionalised Ge nanoparticles were also demonstrated to show an enhanced antioxidant behaviour which could be desirable to improve anticancer activity.³⁸ In this study, we show that structure and morphology of Ge nanoparticles can be controlled by laser irradiation. This suggests that they have potential as an alternative material that can be used in PTT. We also speculate that H-terminated Ge nanoparticles may be used in controlling cell population *in vitro* and potentially *in-vivo*. Furthermore, we suggest that chemical stain etching may in fact be a bottom-up rather than a top-down process, at least in the case of Ge.

II. EXPERIMENTAL METHODS

The chemical stain etching of bulk c-Ge powder (99.999% pure, Sigma-Aldrich) was performed using a solution of HF:H₃PO₄:H₂O₂ (200:200:1)³⁹ for the preparation of Ge nanoparticles (sample p-Ge1). Hydrofluoric acid, HF (48 wt. % in H₂O); phosphoric acid, H₃PO₄ (85 wt. % in H₂O);

^{a)} Author to whom correspondence should be addressed. Electronic addresses: a.karatutlu@qmul.ac.uk and ali.karatutlu@bou.edu.tr. Telephone: +904448268-1166. Fax: +902242114406.

and hydrogen peroxide (30 wt. % in H₂O) were used as-purchased from Sigma-Aldrich. For a second sample (sample p-Ge2), the surface of a commercially available (111) oriented n-type Ge wafer (2 in. in diameter and 0.51 mm thick) was processed in a solution of HF:H₃PO₄:H₂O₂ (34:17:1).^{5,11} Both etching solutions were prepared inside a polytetrafluoroethylene (PTFE) cell and stirred for 3 h (with the aid of a magnetic stirrer) under indoor light illumination during sample preparation. All the chemicals were used in the solution as-purchased from Sigma-Aldrich. The sample prepared from powder (p-Ge1) was re-suspended in ethanol without any further processing. In the sample prepared on the surface of the wafer (p-Ge2), the porous layer was gently scraped with a sharp blade and re-suspended in ethanol.

A third sample of Ge nanoparticles was prepared using a benchtop colloidal synthesis route (named as CS1 henceforth and their preparation and structure shown in our previous studies^{37,40}) so as to test the slow and fast crystallisation on the same sample.

A He-Ne laser beam with a wavelength of 632.8 nm focussed by a 20× objective and power of 2 mW or 60 mW was used for the growth and phase transformation of pGe1 and pGe2 for various exposure time. The Raman data of CS1 were taken using a dispersive Raman spectrometer (Model: The Thermo Scientific DXR Raman Microscope) in which a laser beam of 532 nm wavelength was focussed by a 20× objective and a 50× objective. A higher laser power range (100 mW–800 mW) at a wavelength of 1064 nm and coupled with FT Raman spectrometer (Model: The Thermo Scientific Nicolet NXR 9650 FT-Raman spectrometer) was utilised to test explosive crystallisation of CS1 sample. FT Raman data are usually taken in the near infrared region to detect unsymmetrical molecular bonds. Therefore, Ge-Ge symmetric stretching bond was not observed and FT Raman spectrometer system is only used to record the live video in order to determine at which laser power the explosive crystallisation phenomenon would occur.

The phonon confinement model based on Richter–Fauchet–Campbell model (RFC)^{41,42} was used to obtain the average particle size from the Raman signal. For that purpose, a code has been written in Matlab describing Raman intensity, I as shown below (see in Equation (1)) using the following dispersion relation,⁴³ $\omega_q = \omega_0 - 104\left(\frac{qd_0}{2\pi}\right)^2$:

$$I(\omega) = \int_0^{\frac{2\pi}{a_0}} \frac{e^{-\left(\frac{qd_0}{2\pi}\right)^2} a_0 \pi q^2}{(\omega - \omega_q)^2 + \left(\frac{\Gamma_0}{2}\right)^2} dq, \quad (1)$$

where a_0 is the lattice parameter, q is the phonon wave vector, d_0 is the particle size, ω_q is the phonon dispersion curve, and Γ_0 is the natural linewidth of the Raman peak. $\Gamma_0 = 7 \text{ cm}^{-1}$ is obtained from a calibration standard Ge powder, 99.999% pure, Sigma-Aldrich.

Raman measurements were carried out using a Renishaw 1000 Raman microscope equipped with a 632.8 nm He–Ne laser (The laser spot size was 5 mm). The experimental spectral resolution was 0.5 cm^{-1} . The power was kept at 2 mW during the Raman spectra acquisition with

the typical spectrum collection time was around 1 min. The substrates used in Raman measurements were glass slides for pGe1 and CS1 and a c-Si wafer for pGe2.

For TEM measurements, Ge nanoparticles are suspended in ethanol and then transferred on a commercial Carbon coated Cu grid by submerging the grid into the nanoparticles containing a microtube. TEM measurements were conducted at 200 keV.

III. RESULTS AND DISCUSSION

The first sample (p-Ge1) was prepared from bulk Ge powder. The resulting p-Ge1 nanoparticles were yellow in color, as shown in Figure 1(c). TEM measurements were carried out to confirm the size of the as-prepared sample, and the average typical particle size was found to be $10 \pm 3 \text{ nm}$ (Figure S1). Extended Raman data show the presence of a Ge-H stretching mode at 2048 cm^{-1} (Refs. 44 and 45) (see inset in Figure 1(a)). No signal corresponding to Ge-O modes (at 442 cm^{-1}) was detected. The Raman mode corresponding to the Ge-Ge TO phonon mode was detected at 292 cm^{-1} (see Figure 1(a)). The mode is shifted towards lower frequencies with respect to that of crystalline bulk Ge at 300 cm^{-1} (see Figure 1(a)), has an asymmetric shape, and is broader than that observed in bulk Ge. Broadening and asymmetric peak shape as well as down-shift of the peak are expected for Ge nanoparticles⁷ and is due to phonon confinement effects. The RFC model^{41,42} was applied to estimate the size of Ge nanoparticles. Free-standing p-Ge1 nanoparticles were found to be 7.2 nm in size for an as-prepared sample (Figure S2). The average particle size difference observed between TEM and Raman data can be attributed to the influence of surface-related structural disorder.^{37,40}

Following sample characterisation, we investigated the behavior of as-prepared nanoparticles upon He-Ne laser exposure. Laser power was increased to 2 mW, and the Raman spectra from 1 min of exposure to 100 min of the exposure were recorded (see Figure 1(b)). The most obvious observation is the shift of the Raman peak back to around 300 cm^{-1} (as found in bulk Ge).

Using the RFC model, the size of Ge nanoparticles was obtained and it was found to increase from 7.2 nm to 23.8 nm at the end of 35 min and then to the bulk at the end of 40 min (Figure 1(d) and Table S1). Thus, we conclude that the sample was transformed to bulk Ge at the end of 40 min as indicated by the value of the FWHM of the Raman peak ($\sim 7 \text{ cm}^{-1}$, close to that observed in bulk Ge reference). Further laser exposure in ambient environment yields oxidized Ge nanoparticles and ultimately results in full sample oxidation after 100 min as indicated by the appearance and growth of the Raman mode (at around 442 cm^{-1}) corresponding to alpha-quartz type GeO₂ (see Figures 1(b), S3, and S4, respectively, for the corresponding Raman spectra and the schematic of the growth and phase transformation of free-standing Ge nanoparticles upon exposure of He-Ne laser in the supplementary material). Furthermore, by the end of the exposure period, the Raman signal corresponding to pure Ge (at 300 cm^{-1}) has completely disappeared (see Figure 1(b)).

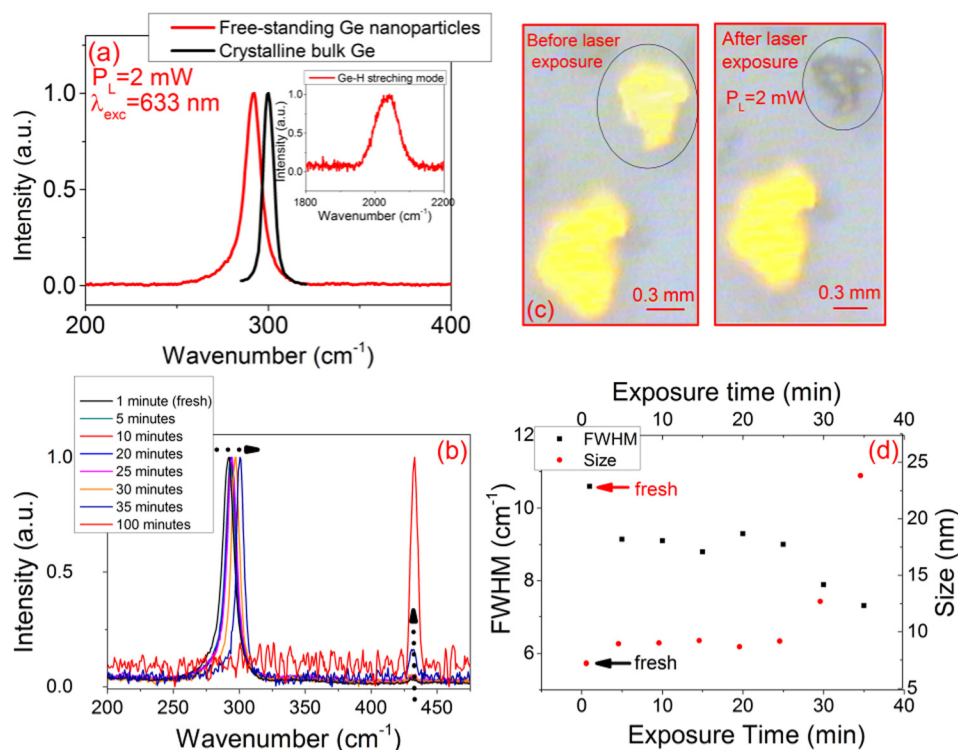


FIG. 1. (a) Raman shift of free-standing Ge nanoparticles before (as-prepared) and that of crystalline bulk Ge. The inset shows Ge-H stretching mode at 2042 cm^{-1} , which is an indication for H-termination of Ge nanoparticles. (b) Raman spectra of Ge nanoparticles exposed to a He-Ne laser light with an excitation wavelength of 633 nm (laser power = 2 mW) from 5 min to 100 min. By the time of the laser exposure, Ge nanoparticles were grown in size. At the end of 35 min, Ge nanoparticles begins transformation to α -type GeO_2 , which was shown with Ge-O stretching mode at 433 cm^{-1} (c) The picture of clusters of Ge nanoparticles before (fresh) and after the laser exposure ($t = 10\text{ min}$). (d) Size (red symbols) and FWHM (black symbols) change of Raman shift of Ge nanoparticles by the time of the He-Ne laser exposure were shown from 1 min (fresh sample) to 35 min. As-prepared Ge nanoparticles were grown from 7.2 nm in size to 23.8 nm in size at the end of 35 min.

The second set of Ge nanoparticles (p-Ge2) was prepared using the same chemical stain etching method on the surface of a Ge wafer. As shown in Figure 2(b), as-prepared p-Ge2 was also yellow in color. The Raman spectrum of as-prepared p-Ge2 is given in Figure 2(a). The size of p-Ge was found to be 3.1 nm (see Figure 2(a)) using the RFC model. The origins of the particle size differences between p-Ge1 and p-Ge2 samples are unclear at present, but may be related to the geometry of the precursors' surface (curved for powder vs planar for wafer) and kinetics of particle formation. Once a Raman spectrum of as-prepared p-Ge2 has been recorded, the laser power was changed to 60 mW and the visual appearance of the sample was observed to change instantly (Figure 2(c)). The Raman spectrum of p-Ge2 after the laser exposure is shown in Figure 2(a). The data show that the Ge nanoparticles were transformed into a bulk-like phase and annealed upon exposure of the laser light. In Figure 2(c), one can see that the samples are black in color after the laser exposure. A concentric burn-like pattern

observed on the Si substrate suggests that the process is accompanied by significant heat release sufficient to cause Si substrate annealing.

Thus, our results for p-Ge1 and p-Ge2 samples suggest that exposure to the laser light results in nanoparticle size increase and a change in morphology and structure. Furthermore, the exposure to 60 mW laser power indicates a significant heat release during crystallisation. The latter clearly suggests a transformation from a metastable (or partially metastable) phase. At this point, the energy is considered to be released due to the transition from the disordered state of Ge nanoparticles to its crystalline state triggered by the laser exposure (Figure S5). Considering the position and width of the Raman peak and the size discrepancy observed between the Raman and TEM measurements, we suggest that this metastable phase is most likely to be disordered diamond-type structure. The presence of disordered Ge was also previously shown in our study using EXAFS techniques.^{37,40} The fact that stain etching of c-Ge yields a

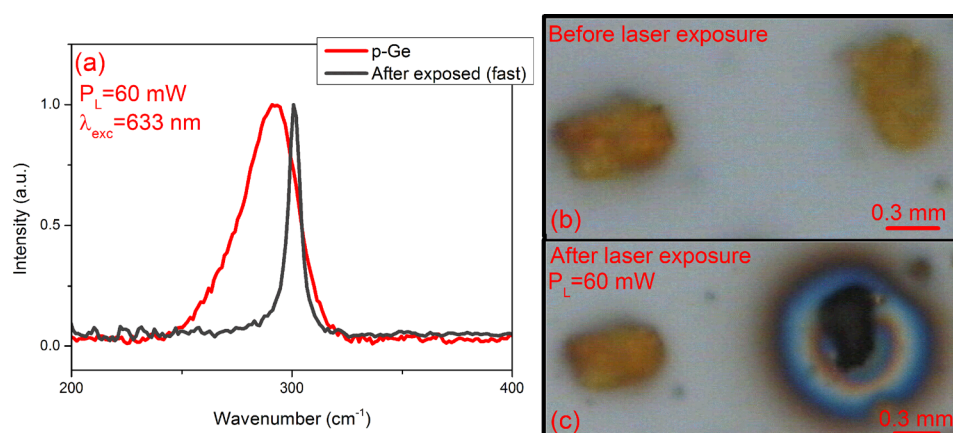


FIG. 2. (a) Raman shift of p-Ge before (as-prepared) and after the prompt laser exposure. (b) The picture of clusters of p-Ge before (fresh) and (c) after the prompt laser exposure. When the laser power is 60 mW , the transformation from the disordered to the crystalline form is prompt which can be observed via the release of the energy from the sample to the environment and was optically recorded as a concentric shell on the substrate.

metastable (amorphous) phase suggests that the process of preparation may not in fact be a top-down as has been previously thought, but a bottom-up one.

When we revisit some of the pioneering chemical stain etching studies of Si^{46–49} in fluoride solutions since 1990s, various chemical solutions but the very same principle were applied. A fluorine containing etchant (e.g., HF or HBF₄ or HSbF₆), an oxidant (HNO₃ or H₂O₂ or H₂O), and sometimes a surfactant with/without a catalyst (a UV-light illumination and a metal ion assistance) were applied to initiate the etching process so as to remove atoms/clusters from a Si wafer which would end with a H-termination on the wafer surface. Recently, Kolasinski reported the modified stain etching mechanism of Si⁵⁰ (also known as Gerischer mechanism⁵¹). The mechanism is rather complex and considered to be occurring in several steps. In the first and the second steps of the etching mechanism, the etching requires a hole (h⁺) formation and transfer of this hole to the surface. In the chemical context, in the first step, the surface is H-terminated which would be later desorbed and then replaced by F⁻ ions in the forthcoming steps. At the end, following these steps will lead to the decomposition of a Si wafer (removal of Si atoms/clusters) and the formation of a porous structure with H-termination on the surface. The same approach was later on applied to germanium using chemical stain etching.^{11,52} Thus, the stain etching mechanism was also interpreted within a similar model—removal of material to form porous structure (see Figure 3). However, it is difficult to explain the formation of a metastable amorphous structure by the mechanism described above. Thus, we suggest that the formation of p-Ge using chemical stain etching may in fact proceed by the removal of atoms/clusters from the bulk precursor followed by the nucleation back onto substrate (when Ge wafer is used) or nucleation and growth in the solution (when powder is used) into partially amorphous nanoparticles (see Figure 3).

We believe that besides shedding fresh light onto the well-known method of nanoparticle preparation, the observed laser effects can find bio-medical and oxygen-harvesting applications. We found two different scenarios of behaviour of Ge nanoparticles when exposed to the laser

light of 2 mW and 60 mW at 632.8 nm. The first scenario is the slow growth and oxidation of the Ge nanoparticles upon the 2 mW laser exposure. Under these conditions, Ge nanoparticles can be considered as an anti-oxidant for controlled up-take of the reactive oxygen species (ROS) in cells. This should provide a valuable tool to study the influence of ROS on cancer development⁵⁴ and perhaps even as a cancer prevention therapy. Furthermore, ROS-mediated strategy was also shown to help reduce drug resistance.⁵⁵ Interestingly, Ge food supplements are already on the market and their positive effects on the immune system were studied by some researchers.^{56,57} Recently, quercetin surface-functionalized Ge nanoparticles were shown to enhance the anti-oxidant and anti-cancer activities.³⁸ Therefore, one can consider Ge nanoparticles as a regulator of the ROS capacity and thus to have significant therapeutic implications.

The second scenario under laser exposure is explosive crystallization with a substantial heat release. Photosensitive smart polymer coated gold nanocages⁵⁸ were successfully demonstrated previously to be used as a drug carrying and release system upon near infrared laser excitation. A variety of nanoparticles—mostly gold^{29–32} and graphene^{33–36}—were used in PTT due to their high thermal conductivity. Here, we speculate that the prompt energy release from free-standing Ge nanoparticles upon He-Ne laser excitation (see Figure 1(d)) may be used to control cell population and proliferation using relatively low laser power. We believe that the energy release from free-standing Ge nanoparticles can be controlled and used in PPT. Particle growth requires proximity of other particles as otherwise there is no material to grow. This suggests that if a cell can take sufficient material then the explosive crystallisation scenario can be used to kill a cell, for example. Our previous studies³⁷ indicate that cells can uptake certain amount of Ge nanoparticles sufficient for imaging applications. However, more work is required to establish specific amounts sufficient for PPT type therapy both *in-vitro* and *in-vivo*.

Furthermore, colloiddally prepared and partially disordered Ge nanoparticles (named as CS1 henceforth and their preparation and structure shown in our previous studies^{37,40}) were exposed to various laser powers including 0.5 mW,

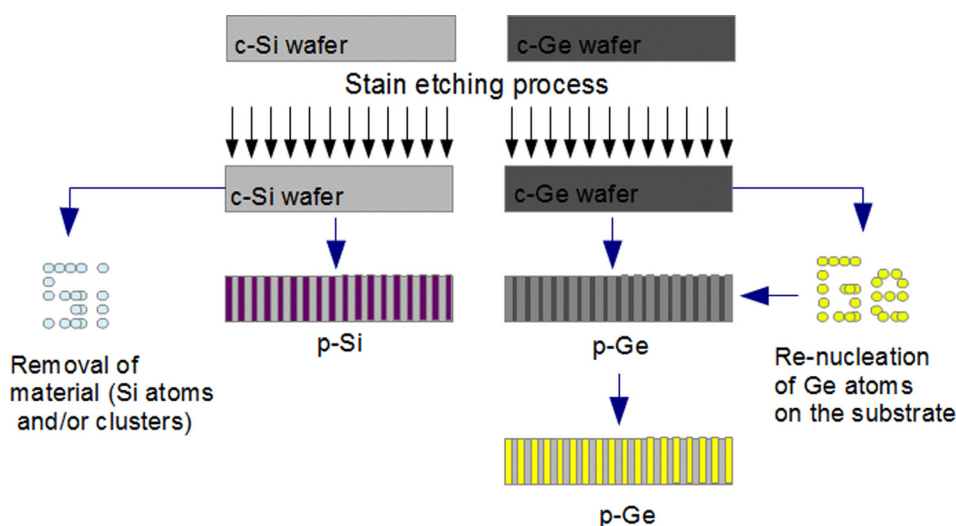


FIG. 3. Schematic of comparison of the etching models of c-Si and c-Ge. In case of etching of c-Si using HF solution, crystalline p-Si is formed (see Ref. 53, nevertheless, the formation of amorphous pGe is considered to be possible due to re-nucleation of pre-etched Ge atoms on the substrate. (Top view)

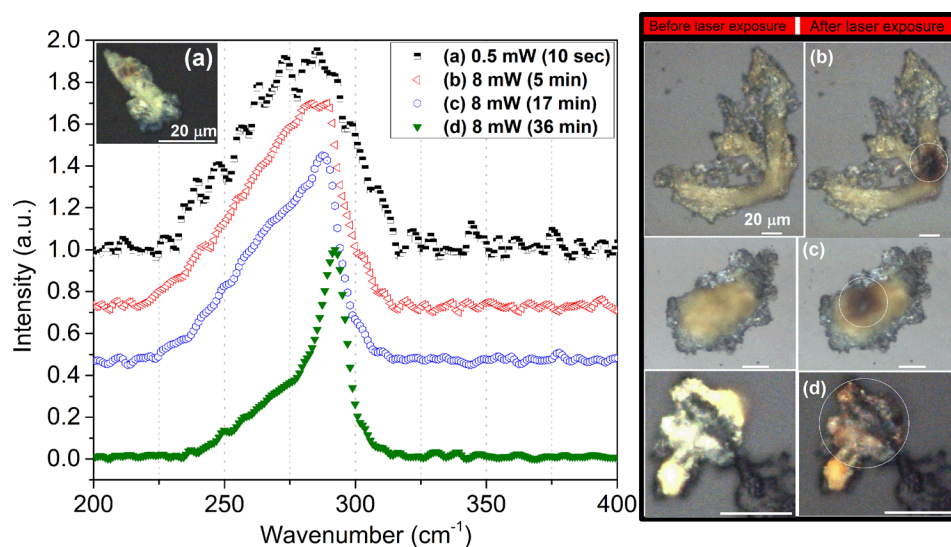


FIG. 4. Raman spectra and visual appearances of (a) as-prepared and the laser exposed Ge nanoparticles at 8 mW for (b) 5 min, (c) 17 min, and (d) 36 min. Scale bars are $20\ \mu\text{m}$. The laser beam was focussed by a $50\times$ and a $20\times$ objectives.

8 mW, and 100–800 mW in order to combine these two scenarios (slow and fast crystallisation) and to perform a systematic study of the laser exposure on the same sample. Raman spectra of CS1 are shown in Figure 4 when the laser power was set to 0.5 mW and 8 mW. Size analyses of CS1 using RFC model after the laser exposure for 10 s at 0.5 mW and for 5 min, 17 min, and 36 min at 8 mW were done and found to be 2.4 nm ($\text{FWHM} = 48.4\ \text{cm}^{-1}$), 2.5 nm ($\text{FWHM} = 43.2\ \text{cm}^{-1}$), 2.7 nm ($\text{FWHM} = 38.1\ \text{cm}^{-1}$), and 5.1 nm ($\text{FWHM} = 15\ \text{cm}^{-1}$), respectively. The characteristics of the size increase of CS1 upon the laser exposure were observed to be consistent with the laser exposed samples prepared by the etching method (see Figure 1(d)).

Images of CS1 samples taken before and after the laser exposure for 5 min, 17 min, and 36 min at 8 mW are shown in Figures 4(b), 4(c), and 4(d), respectively. Later, a higher laser power range (100 mW–800 mW) at a wavelength of 1064 nm was utilised to understand how in the second scenario, explosive crystallisation would take place in CS1 sample. Images of the changes upon the laser exposure with laser power from 100 mW to 700 mW were recorded and are given in Figures 5(a)–5(e). The images from Figures 5(a)–5(c) show that two Ge clusters are exploded when 700 mW laser power was reached. Figure 5(d) shows an image of the case just before the moment of the explosion was recorded and shown in Figure 5(e). The

real time video of the explosive crystallisation of CS1 was also recorded (see video (a) of Ref. 59). In addition, an energy release forms a halo around the Ge cluster when 500 mW of the laser power was set and this process was observed to be reversible and energy release could be controlled by the laser power (see video (b) of Ref. 59). The images as well as the Raman data indicate that the laser exposure at relatively smaller laser power can change the visual appearance and the structure of the Ge nanoparticles. This trend seems to be common in all H-terminated and (partially) disordered Ge nanoparticles (see Figures 1(b), 1(c), 2(a), and 2(c)).

IV. CONCLUSION

We found that Ge nanoparticles prepared by chemical stain etching can undergo transformation to bulk-like crystalline phase. The transformation path depends on laser power and laser exposure time. At relatively low values of the laser power (2 mW) over the period of 100 min, the Raman signal indicates the transformation of the sample from a nanocrystalline to a bulk-like state, followed by partial oxidation and finally a conversion of the entire sample into alpha-quartz type GeO_2 . At a higher laser power (60 mW), we observed heat release during an explosive crystallization of the nanocrystalline material into bulk-like Ge without noticeable

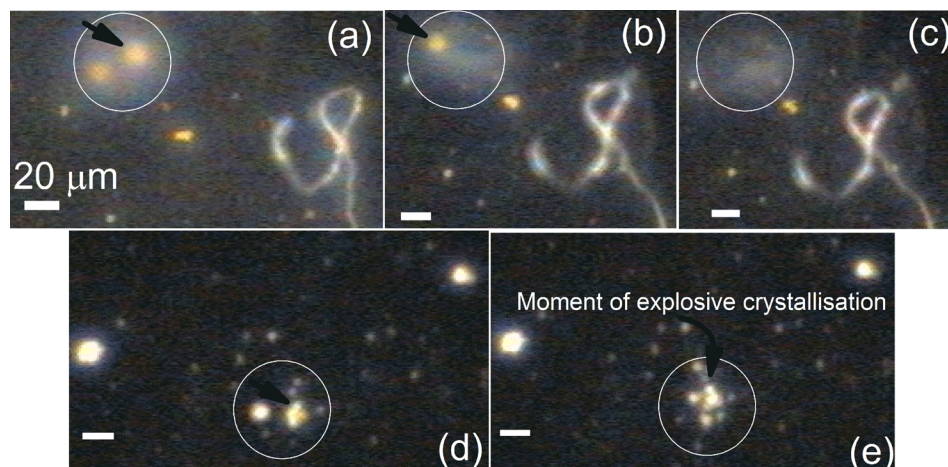


FIG. 5. Visual appearances of CS1 (a) before the explosive crystallisation, the laser beam exposed to the Ge cluster pointed by an arrow whose power was changed from 100 mW to 600 mW and then (b) 700 mW was reached and the explosive crystallisation suddenly took place. In (c), the disappearance of the second Ge cluster pointed by an arrow in (b) is presented. In (d), a Ge cluster was exposed to 100 mW–800 mW and in (e), the shatter of the Ge cluster was shown in the moment of the explosive crystallisation.

signs of oxidation. Together with the transmission electron microscopy measurements, these results suggest that the stain etching method for the preparation of porous Ge may not be a top-down but a bottom-up process. Systematic studies of the laser exposure on Ge nanoparticles prepared by colloidal synthesis shows that explosive crystallisation is shared by H-terminated and (partially) disordered Ge nanoparticles, no matter what the nanoparticle size is. We suggest that the laser effects observed in this work can be used for phototherapy and oxygen harvesting applications.

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